

FOCUSING OF RELATIVISTIC ELECTRON BUNCHES BY NONRESONANT WAKEFIELD EXCITED IN PLASMA

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Focusing of relativistic electron bunches by nonresonant wakefield, excited by them in plasma, is investigated by numerical simulation. For a good focusing bunches are placed optimally relatively to the excited wave. For this the specific difference of wave frequency and bunches repetition frequency is used.

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INTRODUCTION

Focusing of bunches by radial component of wakefield is an important problem. The intensity of this focusing is larger on a few orders in comparison with used magnetic focusing [1]. However focusing, which occurs in the plasma at space charge compensation of bunches, is also not enough intense. The intensity of focusing can be increased significantly, at orientation on its use in colliders, at use of excited transverse wakefield. Focusing by excited resonant wakefield was studied in [2, 3]. Also a uniform focusing by excited wakefield has been studied in [3, 4] for a relatively long bunches and in [5] for short bunches. As in the experiment it is difficult to maintain a uniform and stationary plasma density, resonant for sequence of electron bunches, in this paper focusing of sequence of bunches of relativistic electrons by excited non-resonant wakefield is considered.

1. OPTIMAL NONRESONANT WAKEFIELD PLASMA LENS FOR SHORT SEQUENCE OF IDENTICAL BUNCHES OF RELATIVISTIC ELECTRONS

Numerical simulation has been performed using 2d3v-code lcode [6]. For numerical simulation вибрані Parameters: $n_{res}=10^{11} \text{ cm}^{-3}$ is the resonant plasma density which corresponds to ratio $\omega_{pe}=\omega_m=2\pi \cdot 2.8 \times 10^9$, relativistic factor of bunches equals $\gamma_b=5$, have been selected. ω_m is the repetition frequency of bunches, $\omega_{pe}=(4\pi n_{res}e^2/m_e)^{1/2}$ is the electron plasma frequency. The density of bunches $n_b=6 \times 10^8 \text{ cm}^{-3}$ is distributed in the transverse direction approximately according to Gaussian distribution, $\sigma_r=0.5 \text{ cm}$, $\lambda=10.55 \text{ cm}$ is the wavelength, $\xi=V_b t-z$, V_b is the velocity of bunches. Time is normalized on ω_{pe}^{-1} , distance – on c/ω_{pe} , density – on n_{res} , current I_b – on $I_{cr}=\pi mc^3/4e$, fields – on $(4\pi n_{res}c^2 m_e)^{1/2}$.

As it has been shown in [3], at the resonant excitation of wakefield the shorter first fronts of the bunches are defocused by smaller fields, and longer back fronts of the bunches are focused by larger fields (see Fig. 1).

I.e. focusing by resonant wakefield is strongly inhomogeneous.

Let us consider the optimum parameters for the case of nonresonant wakefield plasma lens for short sequence of identical bunches of relativistic electrons. I.e. we will show that for selected: the length of bunches, less than half the wavelength $\xi_b < \lambda/2$, their number N_b and repeti-

tion frequency of bunches ω_m there is a range of suitable electron plasma frequency ω_{pe} such that all bunches are in focusing wakefields F_r .

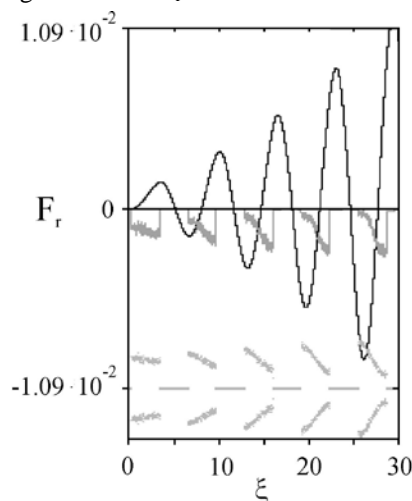


Fig. 1. Longitudinal distribution of radius r_b (horns) and density n_b (trapezoids) of sequence of resonant rectangular bunches and of radial wakefield F_r (oscillating line), after their focusing/defocusing at the distance $z=33 \text{ cm}$ from the boundary of injection at $\xi_b=\lambda/2$, $I_b=0.45 \times 10^{-3}$

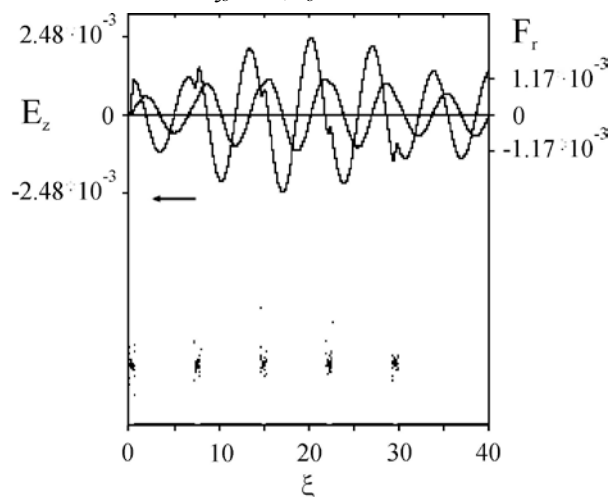


Fig. 2. Longitudinal distribution of radius r_b (points) of sequence of very short approximately Gaussian bunches, of radial wakefield F_r (oscillating line of smaller amplitude) and of longitudinal wakefield E_z (oscillating line of larger amplitude) near boundary of injection at $n_e=1.35 n_{res}$, $\xi_b=0.1 \lambda$, $I_b=1.56 \times 10^{-3}$. The arrow shows the direction of the bunch motion

As it will be demonstrated below, that in the case $\omega_{pe} > \omega_m$ all point (very short) bunches are in focusing or in a zero radial field, we use the range of parameters when $\omega_{pe} > \omega_m$. For determination the optimal parameters we use two conditions. Namely, that all N_b are placed on the length of a beating, it is necessary $0 < \omega_{pe} - \omega_m < \omega_{cr}$. ω_{cr} is some critical frequency, associated with N_b . At the same time, for all the electrons of all bunches are in focusing wakefields, it is necessary $\xi_b < \xi_{cr}$.

In the case of point $\xi_b \rightarrow 0$ bunches one restriction is removed, and the relative position of bunches and F_r at $n_e/n_{res} - 1 = 0.35$ (n_{res} is determined from $(4\pi n_{res} e^2/m_e)^{1/2} = \omega_m$) has the form shown in Fig. 2.

One can see that $N_b = 5$ bunches are in focusing wakefields F_r .

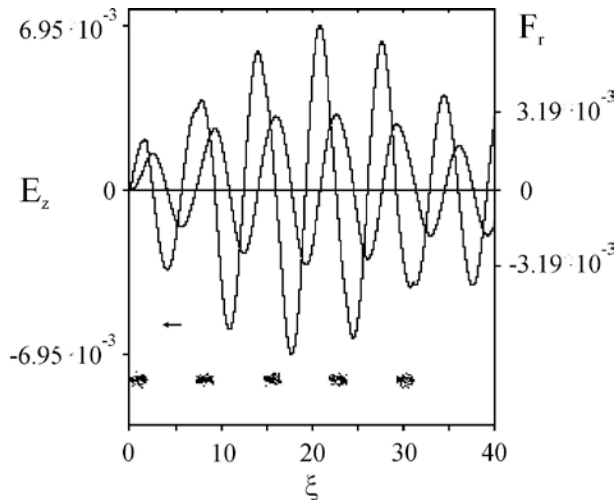


Fig. 3. Longitudinal distribution of radius r_b (short linear segments) of sequence of rectangular bunches of length, $\xi_b = \lambda/4$, of radial wake force F_r (oscillating line of smaller amplitude) and of longitudinal wakefield E_z (oscillating line of larger amplitude) near boundary of injection at $n_e = 1.35 n_{res}$, $I_b = 10^{-3}$

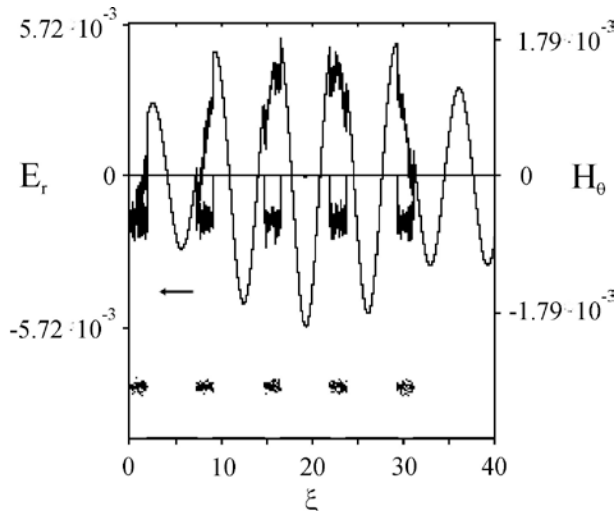


Fig. 4. Longitudinal distribution of radius r_b (short linear segments) of sequence of rectangular bunches of length $\xi_b = \lambda/4$, of radial wakefield E_r (oscillating line) and of magnetic wakefield H_θ (trapezoids) near boundary of injection at $n_e = 1.35 n_{res}$, $I_b = 10^{-3}$

In the case of bunches of finite length, $\xi_b = \lambda/4$ at the plasma density, equal to $n_e = 1.35 n_{res}$, the relative position

of bunches and F_r has the form shown in Figs. 3, 4. F_r is the total, i.e. radial field of the space charge of the bunch, wakefield and its own magnetic field of the bunch current H_θ . E_r is the total, i.e. radial field of the space charge of the bunch and wakefield. As one can see, for each frequency difference $\omega_{pe} - \omega_m$ there exist the length of sequence and the length of the bunches, when all the electrons of all bunches are in focusing fields.

2. FOCUSING OF LONG SEQUENCE OF RELATIVISTIC ELECTRON BUNCHES BY NONRESONANT WAKEFIELD

Let us consider the distribution of long sequence of short relativistic electron bunches (Fig. 5) relative to excited wakefield beatings at $\omega_{pe} > \omega_m$ (Fig. 6).

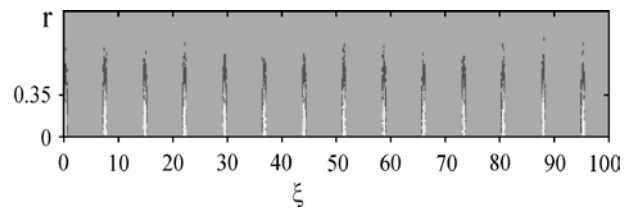


Fig. 5. Spatial distribution of density n_b of sequence of very short approximately Gaussian bunches $\xi_b = 0.1 \lambda$ near boundary of injection at $n_e = 1.35 n_{res}$, $I_b = 1.56 \times 10^{-3}$

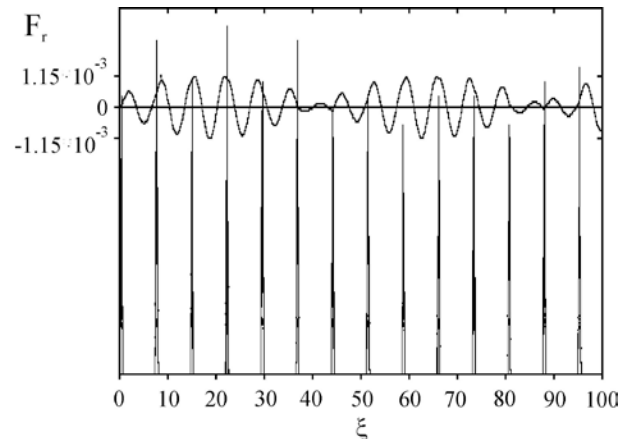


Fig. 6. Longitudinal distribution of density n_b (vertical lines) of sequence of very short approximately Gaussian bunches $\xi_b = 0.1 \lambda$ and of radial wake force F_r (oscillating line) near boundary of injection at $n_e = 1.35 n_{res}$, $I_b = 1.56 \times 10^{-3}$

At $\omega_m < \omega_{pe}$ beatings are excited. All bunches are in focusing fields of beatings except at fronts of beatings, where they are not focused.

In the case of bunches of length $\xi_b = \lambda/4$, $\lambda = 2\pi V_b/\omega_p$ one can see Fig. 7 and Fig. 8.

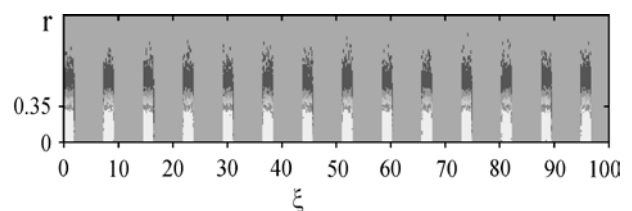


Fig. 7. Spatial distribution of density n_b of sequence of rectangular bunches of length $\xi_b = \lambda/4$ near boundary of injection at $n_e = 1.35 n_{res}$, $I_b = 10^{-3}$

All bunches are in focusing fields except at fronts of beatings, where they are not focused.

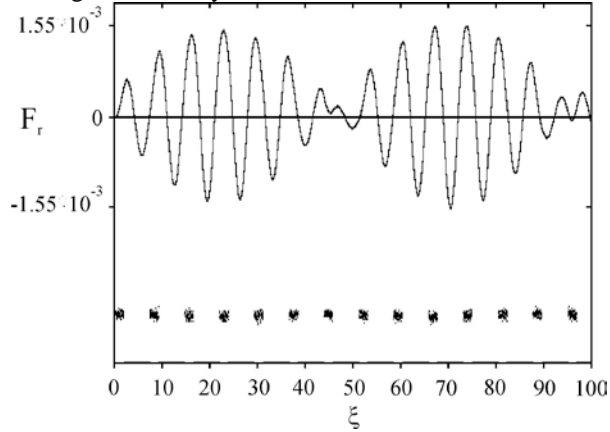


Fig. 8. Longitudinal distribution of radius r_b (short linear segments) of sequence of rectangular bunches of length $\xi_b = \lambda/4$ and of radial wake force F_r (oscillating line) near boundary of injection at $n_e = 1.35 n_{res}$, $I_b = 10^{-3}$

Let us compare focusing in nonresonant (Fig. 9) $\omega_m < \omega_{pe}$ and in resonant (Fig. 10) $\omega_m = \omega_{pe}$ cases.

One can see that in nonresonant case all bunches are focused except at fronts of beatings, where they are not focused.

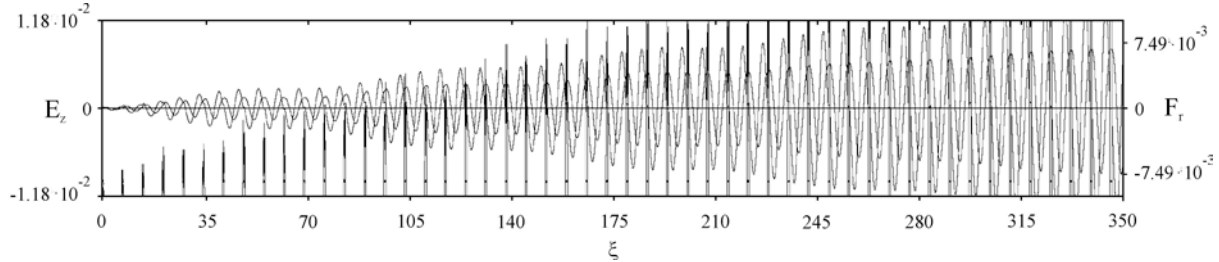


Fig. 11. Longitudinal distribution of radius r_b (points) and density (vertical lines) of long shaped according to linear dependence sequence of very short bunches, of radial wake force F_r (oscillating line of smaller amplitude) and of longitudinal wakefield E_z (oscillating line of larger amplitude) near boundary of injection at $I_b = 10^{-3}$

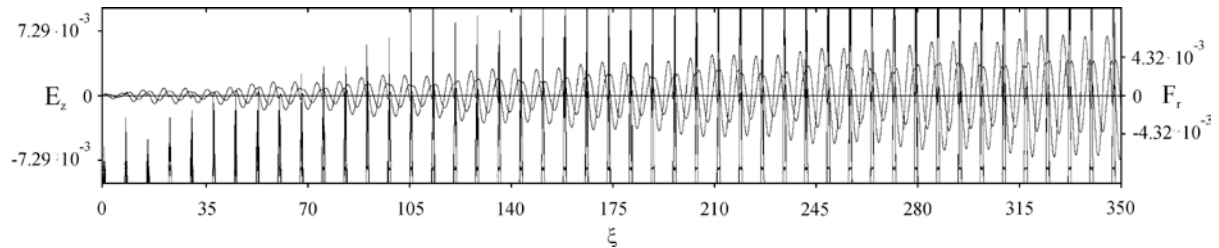


Fig. 12. Longitudinal distribution of radius r_b (points) and density (vertical lines) of long shaped according to linear dependence sequence of approximately Gaussian bunches, the length of which equals $\xi_b = \lambda/5$, of radial wake force F_r (oscillating line of smaller amplitude) and of longitudinal wakefield E_z (oscillating line of larger amplitude) near boundary of injection at $I_b = 2.5 \times 10^{-3}$

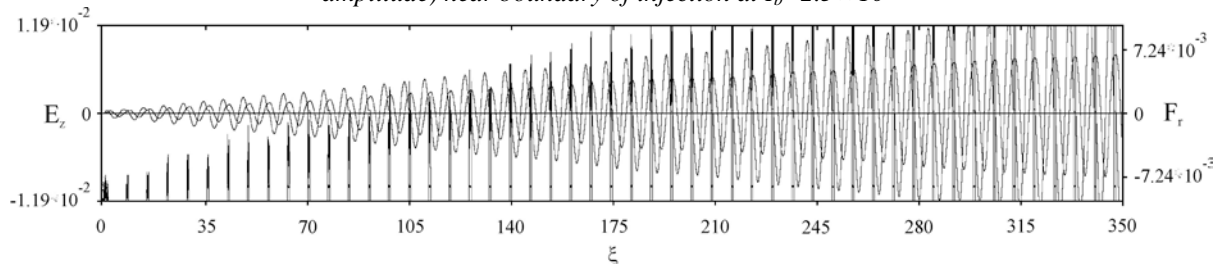


Fig. 13. Longitudinal distribution of radius r_b (points) and density (vertical lines) of long sequence with precursor shaped according to linear dependence along sequence as well as along each bunch, of radial wake force F_r (oscillating line of smaller amplitude) and of longitudinal wakefield E_z (oscillating line of larger amplitude) near boundary of injection at $I_b = 10^{-3}$

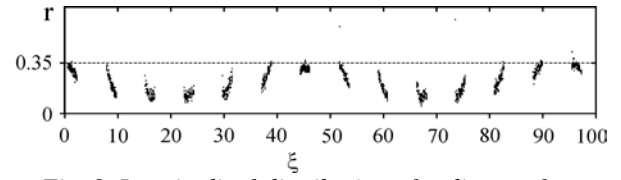


Fig. 9. Longitudinal distribution of radius r_b of sequence of rectangular bunches of length $\xi_b = \lambda/4$ at $n_e = 1.35 n_{res}$, $I_b = 10^{-3}$ after their focusing at the distance $z = 50$ cm from the boundary of injection

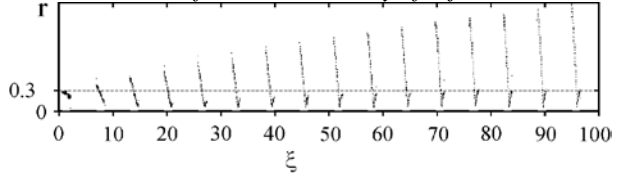


Fig. 10. Longitudinal distribution of radius r_b of resonant sequence of rectangular bunches of length $\xi_b = \lambda/4$ at $I_b = 10^{-3}$ after their focusing/defocusing at the distance $z = 50$ cm from the boundary of injection

Now we consider the long sequence of short Gaussian bunches. The sequence is shaped according to linear dependence. The space interval between bunches equals to the wavelength (see Fig. 11).

One can see that all bunches are in maxima of focusing field and thus they are decelerated slowly, as they are in zero decelerating field, excited by previous bunches.

Now we consider the long sequence of Gaussian bunches, shaped according to linear dependence. The space interval between bunches is equal to the wavelength, and the bunch length equals $\xi_b = \lambda/5$ (Fig. 12). Also we consider a long sequence of short bunches with precursor, shaped according to linear dependence along the sequence and along each bunch (Fig. 13). The space interval between bunches equals wavelength. One can see that in both cases all bunches are in maximal focusing fields and in a small E_z .

Thus, bunches of sequence, shaped according to linear dependence, and bunches of sequence, shaped according to linear dependence with precursor, are in maximal focusing fields.

CONCLUSIONS

Focusing of relativistic electron bunches by nonresonant wakefield, excited by them in the plasma, has been investigated by numerical simulation. For an efficient focusing the bunches are placed optimally with respect to the excited wave. For that it uses a determined difference of wave frequency and repetition frequency of bunches.

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ФОКУСИРОВКА РЕЛЯТИВИСТСКИХ ЭЛЕКТРОННЫХ СГУСТКОВ НЕРЕЗОНАНСНЫМ КИЛЬВАТЕРНЫМ ПОЛЕМ, ВОЗБУЖДАЕМЫМ В ПЛАЗМЕ

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Исследуется численным моделированием фокусировка релятивистских электронных сгустков нерезонансным кильватерным полем, возбуждаемым ими в плазме. Для хорошей фокусировки сгустки размещаются оптимальным образом относительно возбуждаемой волны. Для этого используется определенная разность частоты волны и частоты следования сгустков.

ФОКУСУВАННЯ РЕЛЯТИВІСТСЬКИХ ЕЛЕКТРОННИХ ЗГУСТКІВ НЕРЕЗОНАНСНИМ КІЛЬВАТЕРНИМ ПОЛЕМ, ЩО ЗБУДЖУЄТЬСЯ В ПЛАЗМІ

В.І. Маслов, І.П. Левчук, І.М. Онищенко

Досліджується чисельним моделюванням фокусування релятивістських електронних згустків нерезонансним кильватерним полем, яке збуджується ними в плазмі. Для хорошого фокусування згустки розміщуються оптимальним чином щодо хвилі, яка збуджується. Для цього використовується певна різниця частоти хвилі і частоти слідування згустків.